



IFW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Masaharu KAWAKUBO et al.

Group Art Unit: 2851

Application No.: 10/581,060

Docket No.: 127873

Filed: May 30, 2006

For: EXPOSURE METHOD AND DEVICE MANUFACTURING METHOD,
EXPOSURE APPARATUS, AND PROGRAM

SECOND REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

A Request for Correction of PALM Records was filed on February 16, 2007. A copy of the Request, a marked-up copy of the Official Filing Receipt and a date stamped receipt is attached hereto.

It is respectfully requested that the Corrected Filing Receipt be immediately forwarded to the attorneys of record at the address set forth below.

Respectfully submitted,

Mario A. Costantino
Registration No. 33,565

Randi B. Isaacs
Registration No. 56,046

MAC:RBI/ejw

Date: July 13, 2007

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Alexandria, Virginia 22320
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P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

Mario A. Costantino
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Stephen P. Catlin
Registration No. 36,101

MAC:SPC/ejw

Date: February 16, 2007

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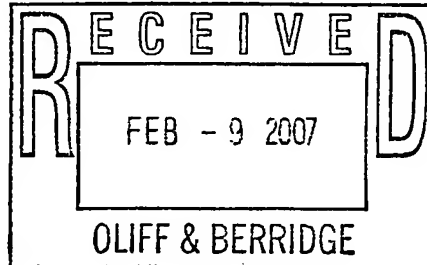


UNITED STATES PATENT AND TRADEMARK OFFICE

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/581,060	05/30/2006	2851	2230	127873	13	32	6

25944
OLIFF & BERRIDGE, PLC
P.O. BOX 19928
ALEXANDRIA, VA 22320



CONFIRMATION NO. 6788

FILING RECEIPT



OC000000022361515

Date Mailed: 02/07/2007

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Masaharu Kawakubo, Saitama-ken, JAPAN;
Yuho Kanaya, Saitama-ken, JAPAN;
Chiaki Nakagawa, Saitama-ken, JAPAN;
Takahisa Kikuchi, Saitama-ken, JAPAN;
Masahiko Akizuki, Saitama-ken, JAPAN;

Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/17447 11/25/2004

Foreign Applications

JP 2003-400210 11/28/03

If Required, Foreign Filing License Granted: 02/06/2007

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/581,060**

Projected Publication Date: 05/17/2007

Non-Publication Request: No

Early Publication Request: No

Title

Exposure method and device manufacturing method, exposure apparatus, and program

Preliminary Class

355

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PTO RECEIPT FOR FILING OF PAPERS**Delivery ▶ Mail Room****The following papers have been filed:**

Request for Correction of PALM; marked-up copy of OFR

Name of Applicant:	Masaharu KAWAKUBO; Yuho KANAYA; Chiaki NAKAGAWA; Takahisa KIKUCHI; Masahiko AKIZUKI
Serial No.:	10/581,060
Attorney File No.:	127873
Title:	Exposure Method and Device Manufacturing Method, Exposure Apparatus, and Program
Sender's Initials:	MAC:SPC/ejw
Assignee:	NIKON CORPORATION

PATENT OFFICE DATE STAMP**COPY TO BE STAMPED BY PATENT OFFICE
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